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Recent Development-2 of CADTEL Software: The Optimum Conditions of Scherzer Imaging in the Electron Magnetic Lenses

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Abstract

CADTEL software was developed to provide the simplest and most versatile computing resource that a wide range of skilled researchers and designers can use. In this paper, a development on this program, relying on sixteen mathematical models, produced a new version of CADTEL software package which focuses on the optimum conditions of Scherzer imaging for round electron magnetic lenses.. These models depend on synthesis procedure which is mainly designed to work with the inverse design problem, and represent the axial magnetic flux density of desirable electron magnetic lens which can be proposed or selected , using the four (zero, low, high, infinite) magnification states. The program provides the freedom of selecting multiple models and changing its variables (which appear on the home page), in addition to providing facilities for numerous proposed magnetic lens. The objective properties calculated in the program were used to compute and plot the optimum conditions for Scherzer imaging

The CADTEL software was written in Visual Basic -6, in an easy-to-use mode, even for a beginner computer user. The results of the analysis clearly show that there is an excellent equivalent calculation which could be obtained for the same lens from CADTEL software when evaluated with other counterpart software.

Keywords: Magnetic lens, Scherzer imaging, spherical aberration, resolution limit.

التطوير الحديث-2 لبرنامج CADTEL: الشروط المثلى لتصوير شيرزر للعدسات الكهرومغناطيسية.

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الخلاصة

في السابق، تم تطوير برنامج CADTEL لتوفير أبسط موارد الحوسبة وأكثرها تتوعًا والتي يمكن لمجموعة واسعة من الباحثين والمصممين المهرة استخدامها. بينما، التطوير الحالي المقدم في هذا البحث, هو نسخة جديدة من حزمة برامج CADTEL حيث الاهتمام بالشروط المثلى لتصوير شيرزر للعدسات المغناطيسية الإلكترونية المدورة، ضمن ستة عشر نموذجًا رياضيًا. تعتمد هذه النماذج على الطريقة التوليفية في التصميم بشكل أساسي للعمل مع مشكلة التصميم العكسي وتمثيل كثافة الفيض المغناطيسي المحوري للعدسة المغناطيسية الإلكترونية المرغوبة والتي يمكن اقتراحها أو اختيارها باستخدام حالات التكبير الأربعة (الصغري، الواطيء، العالي، و اللانهائي). البرنامج يوفر لنا حرية اختيار نماذج متعددة وتغيير معاملاتها (التي تظهر

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في الصفحة الرئيسية للبرنامج) وتسهيلات للعديد من العدسات المغناطيسية المقترحة. تستخدم الخواص الشيئية
المحسوبة في البرنامج لحساب ورسم الشروط المثلى لتصوير شيرزر.
تمت كتابة برنامج CADTEL في لغة فيجوال بيسك (Visual Basic - 6)، بشكل سهل الاستخدام حتى في
حالة وان كان مستخدم الكمبيوتر مبتديء. تظهر نتائج التحليل بوضوح أن هناك تكافوء ممتاز يمكن الحصول
عليه لنفس العدسة من برنامج CADTEL عند تقييمه باستخدام برنامج نظيرة آخرى.
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1. Introduction

1.1 Background

The CADTEL software [1], is a package of programs in the field of design and simulation for charged particles optics, is to be develop in the current paper. Since the beginning of the second half of the last century, the idea of using a computer as a tool for analyzing electron lenses has been observed, when several simple and restricted trails such as Lenz 1950, Liebmann and Grand 1951, Liebmann 1953, and Heath 1966 have been published [2]. Actually, Munro, in 1973, launched the first serious computer-aided investigation into electron lenses [3]. In 1984, Lencová introduced software similar to that of Munro to deal with additional features of a relatively wide analyzed area for magnetic lenses. A numerous of software and simulation programs in electron optics have been presented such as; SOFEM [4], PBO Lab [5], SPOC programs [6], Beam Optics Analysis (BOA) [7], SIMION-7 version [8], MULTIMAG program [9], Electron Optical Design "EOD" [10], Charged Particle Optics "CPO" programs [11], "Focus" software [12], SIMION-8 version [13], "MEBS" software [14], OmniTrak software [15], and ANSYS software [16].

1.2 Optimization

The basic goal of the optimization technique in the field of electron and ion optical systems is to produce electrodes or pole-pieces systems that provide focusing properties with minimum aberrations. That is, the approach aims to improve the quality of the electron device in general and any desirable procedure that leads to the optimum design of an optical electron system. There are two very different optimization methods in the context of electron and ion optics which are analysis and synthesis [17].

Synthesis optimization procedure can be defined as two-step mathematical processes: the first involves optimizing a certain target function (i.e. axial field, axial potential, trajectory of charged particle beams) for specific operational conditions. Whereas, the second step aims to rebuild a lens system that can achieve the optimized target function that was achieved in the first phase [18]. Subsequently spherical aberration which results from objective properties is used to determine the optimum conditions of Scherzer imaging and other parameters in the electron magnetic lenses.

2. Math Concepts

2.1 Mathematical Field Models

Once the synthesis procedure is adopted for executing the optimization procedure, the objective (or target) function should be defined first. However, in the current paper the target function is mainly concerned with approximating the axial flux density (B_z) by a well-known mathematical model. Sixteen different forms were considered (see Table 1), from which the axial magnetic field could be determined and so initiate the synthesis procedure.

Model No.	Model Name	Model Math Form
1	Glaser Bell-Shaped	$B_z = B_{max} / [1 + (z / a)^2]$
2	Grivet-Lenz	$B_z = B_{max} / [cosh(1.317 z / a)]$
3	Exponential Field	$B_z = B_{max} \exp(-z \ln 2 / a)$
4	Spherical Pole-Piece	$B_z = B_{max} (3.847)^3 / [3.847 + (z / a)]^3$
5	Gaussian Field	$B_z = B_{max} \exp[-(z/a)^2 \ln 2]$
6	Fourth Exponent	$B_z = B_{max} / [1 + (z / a)^4]$

Table 1- The Expressions of Mathematical Field Models [19]

7	Three Halves Exponent	$B_z = B_{max} / [1 + (z / a)^{3/2}]$
8	Inverse Hyperbolic Sine Function	$B_z = B_{max} / \sqrt{1 + (2\sqrt{3} z / a)^2}$
9	Inverse Tangent Function	$B_z = B_{max} / [1 + (2z / a)^2]$
10	Hyperbolic Tangent	$B_z = B_{max} [1 - {tanh(1.76275(z / a))^2}]$
11	Mixed	$B_z = B_{max} \tan^{-1}(z / a) / \sinh(z / a)$
12	Trigonometric function	$B_z = B_{max} / [{cosh(z / a)}^2 \sqrt{2 + tanh(z / a)}]$
13	Quadratic Secantsh	$B_z = B_{max} [sech(1.135 z / a)]^2$
14	Powered Hyperbolic Secantsh	$B_z = B_{max} [sech(180 z / (z_2 - z_1))]^N$
15	Cosine Field	$B_z = B_{max} [\cos{z (\cos^{-1}(0.5))^{1/N} / W}]^N$
16	HSH	$B_z = B_{max} \cdot r^4 / (Z^2 + r^2)^2$

2.2 Math Relations and Scherzer Optimum Conditions

2.2.1 The Coefficient of Spherical Aberration and Wavelength

The spherical aberration is a blurring phenomenon that occurs if a lens can not converge incoming rays, those of high incidence angles, to the focal point but directs them to a point that is closer to the lens. This will spread an image point in the image plane (ideally pictured as a single point in the gaussian image plane) over a finite size disc.

For an objective lens, only the spherical and chromatic aberrations are important, since the combined effects of electron wavelength and spherical aberration set the electron-optical resolution limit. While radial and spiral distortions are the most important for intermediate and projector lenses since they cause an image point shift with no blurring [20].

The spherical aberration can be calculated from the integral formula below [20]:

$$C_{s} = \frac{\eta}{128V_{r}} \int_{z_{0}}^{z_{i}} \left[\frac{3\eta}{V_{r}} B_{z}^{4} r_{\alpha}^{4} + 8B_{z}^{\prime 2} r_{\alpha}^{4} - 8B_{z}^{2} r_{\alpha}^{2} r_{\alpha}^{\prime 2} \right] dz$$
(1)

The wavelength (λ in nm) of electron beam is related to its speed (v), which is set by the accelerating voltage (V in volts) in the form [21]:

$$\lambda$$
 (nm) = h / m.v = [(h² / 2 e.m) / V]^{1/2} = (1.5 / V)^{1/2}=1.23x10⁻⁶ V^{1/2} (2)

Where h is Planks constant and is equal 6.63×10^{-34} J.s, e and m are the charge and the mass of electron, respectively.

2.2.2 Resolution and Resolving Power

Lord Rayleigh, in 1874, developed the most widely used concept of resolution. He proposed a resolution criterion required for the use of a telescope to discriminate between two stars. Thus, this example

is being used to explain the resolution principle but the findings usually apply to other forms of imaging tools such as cameras and microscopes.

Rayleigh principle states; "The midway brightness between the two points is 0.81 of the brightness at the points they are themselves. We can find that to be around the limit of closeness at which some definite indication of resolution may be present".

The point resolution or resolution limit (δ) is defined by the smallest distance (closest spacing) at which two points can be resolved or can clearly be seen through the microscope to be two separate entities [21].

Scherzer's optimum resolution limit in optimum conditions for coherent and incoherent imaging circumstances is given by [22]:

$\delta_{ORLCSI} = 0.667 (C_S \lambda^3)^{1/4}$	for coherent imaging	(3)
a = 0.01 (0.13)1/4		

$\delta_{\text{ORLICSI}} = 0.61 (C_{\text{s}} \lambda^{\circ})^{-1}$	in TEM for incoherent imaging	(4)
$\delta_{ORLICSI} = 0.43 (C_s \lambda^3)^{1/4}$	in STEM for incoherent imaging	(5)

It should be noted that, for incoherent imaging, the Scherzer resolution condition (Eq.5) is significantly higher than that for coherent imaging (Eq. 3) [23]. While the resolving power (γ) (in nm-1) is the inverse of resolution limit, and so the last three equations can be formed as:

(15)

$\gamma_{ORLCSI} = 1.499 (C_S \lambda^3)^{-1/4}$	for coherent imaging	(6)
$\gamma_{\text{ORLICSI}} = 1.639 (\text{C}_{\text{s}} \lambda^3)^{-1/4}$	in TEM for incoherent imaging	(7)
$\gamma_{\text{ORLICSI}} = 2.325 (C_{\text{s}} \lambda^3)^{-1/4}$	in STEM for incoherent imaging	(8)

It must noted that, for incoherent imaging, the Scherzer resolution power (resolution condition) is significantly higher than that for coherent imaging [23]. Thus, Scherzer resolution power (Scherzer cutoff frequency or spatial frequency) (γ_{Sch}) is the highest transferred frequency [23], [24]:

$$\gamma_{\rm Sch} = [6 / (C_{\rm s} \lambda^3)]^{1/4} = 1.565 (C_{\rm s} \lambda^3)^{-1/4}$$
(9)

The minimum value of Scherzer resolution power $(\gamma_{sch})_{min}$ is:

$$(\gamma_{\rm Sch})_{\rm min} = 0.385 \,({\rm C}_{\rm s}\,\lambda^3)^{-1/4}$$
 (10)

2.2.3 Optimum Aperture

The optimum angular, semi-angle aperture, in Scherzer imaging is given by [22]:

 $\alpha_{\rm oSch} \,({\rm rad}) = 1.51 \,(\,\lambda \,/\,{\rm C_S})^{1/4}$ for coherent imaging (11)

 $\alpha_{\rm oSch}$ (rad) = 1.41 ($\lambda / C_{\rm S}$)^{1/4} for incoherent imaging (12)

Where α is the semi-angle of cones of rays leaving the object point. So, the optimum aperture gives the minimum spot size.

The aperture can be formed in other cases:

$$\alpha_{\text{Hawk}} (\text{rad}) = 0.77 (\lambda / C_s)^{1/4}$$
 up to Hawkes, 1982 [21] (13)
$$\alpha_{\text{Klem}} (\text{rad}) = (\lambda / C_s)^{1/4} = 0.006 / (C_s^{1/4} V^{1/8})$$
 up to Klemperer, 1971 [25] (14)

2.2.4 Optimum Scherzer Defocus

It is estimated that the deviation of a defocused ray from the ideal is by stating the longitudinal aberration, a measure of how much a ray deviates from the focal point along the optical axis, as opposed to the spherical aberration. The defocus value (Ψ) can be used to counteract the spherical aberration in order to allow a greater contrast in the process. Scherzer developed this analysis, and is called Scherzer defocus (Ψ_{Sch}) and is formed as [26]: $)^{1/2}$

$$\Psi_{\rm Sch} = (C_{\rm s} \lambda)$$

In the Scherzer defocus, the optimal image condition in bright field mode occurs [27]. Otto Scherzer, in 1949, found that the optimum defocus depends on the microscope properties provided by the electrons, such as the spherical aberration coefficient (Cs), and the electron wavelength (λ) or accelerating voltage (V_r), and is given by:

$$\Psi_{\rm OSch} = -1.2 \, (C_{\rm s} \, \lambda)^{1/2} \tag{16}$$

Where the Scherzer defocus extension is defined by factor 1.2. In general, it is the best defocus for taking images from HRTEM (High Resolution TEM) [28]. Thus, the extended Scherzer defocus is:

$$\Psi_{\text{Sche1}} = (1.5 \text{ C}_{\text{s}} \lambda)^{1/2} = 1.2247 (\text{C}_{\text{s}} \lambda)^{1/2}$$
(17)

And the extended second broadband Scherzer defocus is: (18)

$$\Psi_{\text{Sche2}} = (3.5 \text{ C}_{\text{s}} \lambda)^{1/2} = 1.87 (\text{C}_{\text{s}} \lambda)^{1/2}$$

The second of these, is widely used to describe different image resolution scales.

Additionally, Pennycook and Nellist, in 1997, introduced the optimum conditions for coherent, and incoherent Scherzer imaging circumstances as follows [22]:

$$\Psi_{\text{OSchc}} = -1.15(\text{C}_{\text{s}} \lambda)^{1/2} \qquad \text{coherent imaging} \tag{19}$$

$$\Psi_{\text{OSchi}} = -(\text{C}_{\text{s}} \lambda)^{1/2} \qquad \text{incoherent imaging} \tag{20}$$

2.2.5 Scherzer Contrast

Mathematically, the contrast transfer function (CTF) explains how aberrations in a transmission electron microscope (TEM) changes a sample image [29], [30]. This CTF sets the resolution of HRTEM, also known as phase contrast of TEM.

The contrast in HRTEM comes from interference between the phases of scattered electron waves with the transmitted electron wave phase in the image plane.

The image would exactly represent the object function in an ideal microscope, and the image intensity for a function of a pure phase object would be equal to 1, that is, the image would show no contrast. This can be compared in an ideal optical microscope with imagery of a glass plate with variable thickness. Thin material objects also behave as phase objects in the transmission electron microscope. In electron microscope , the phase shift for a range of beams can be made approximately equal to $-\pi/2$ if it is operated at optimum focus where a fortunate balance between spherical aberration and defocus is achieved through phase contrast. In addition, the period for a thin object is proportional to the object 's projected potential such that the image contrast can be directly interpreted in terms of the object 's projected structure [24].

Complex interactions occur when an electron wave passes through a sample in TEM. The electron wave above the sample can be approximated as a plane wave.

Owing to spherical aberration and defocus, Scherzer contrast or total phase shift (χ) is:

 $\chi = \pi \Psi \lambda \gamma_{\text{Sch}}^2 + 0.5 \pi C_s \lambda^3 \gamma_{\text{Sch}}^4$ (21) According to the last equation (Eq. 21), it should be noted that the phase shift or Scherzer contrast (χ) depends upon and increases with Scherzer cutoff frequency or resolution power (γ_{Sch}). The process of imaging is also influenced by the effects of spatial and temporal incoherences. Spatial incoherence occurs because the illuminating beam is not parallel but can be considered as a cone of incoherent plane waves (beam convergence). The image, then, results from a superposition of the intensities of the respective images. Temporary incoherence arises from variations in (a) the energy of the thermally released electrons, (b) the lens currents and (c) the accelerating voltage. So, the above effects cause the focus electrons to fluctuate.

5. Results and Discussion Home Page of Optimum Conditions for Scherzer Imaging.

From the home page of the program , model no.1 was selected ,where $B_{max} = 0.5$ Tesla, $z_1 = -10$ mm, $a_1 = 0.5$ mm, $a_2 = 0.5$ mm (symmetric lens) for Glaser Bell-Shaped Model (GBSM) and using its magnetic flux density (B_z) and zero magnification condition (ZMC) as a case study to compute the optimum conditions for Scherzer imaging (as in Table 2). These parameters were plotted (see Figure 1) to study their behaviors. The outcome results supply the searcher in benefit feedback about the proposed model (lens) from auto use in FILE, EDIT, VIEW, COMPUTE AND PLOT, PATH NAME, and HELP options which are available in the task bar in the home page of this software development according to user need, as shown in Figure 2.



Figure 1-Home Page of Optimum Conditions for Scherzer Imaging.

LE EDIT	VIEW	COMPUTE AND PLOT PATH NAME			ORLCSI x NI/sqrt(Vr)
		AXIAL FLUX DENSITY DISTRIBUTION			ORLICSITEM x NI/sqrt(Vr)
		SCALAR POTENTIAL			ORLICSISTEM x NI/sqrt(Vr)
		FLUX DENSITY AND SCALAR POTENTIAL			ORPCSI x NI/sqrt(Vr)
		POLES PROFILE RECONSTRUCTION			ORPICSITEM x NI/sqrt(Vr)
		OBJECTIVE PROPERTIES	>		ORPICSISTEM x NI/sqrt(Vr)
		PROJECTOR PROPERTIES)		RPSI x NI/sqrt(Vr)
		OPTIMUM CONDITIONS OF SCHERZER IMAGING)	ZERO MAGNIFICATION	RPminSI x NI/sqrt(Vr)
				LOW MAGNIFICATION	OACSI x NI/sqrt(Vr)
			1	HIGH MAGNIFICATION	OAICSI x NI/sqrt(Vr)
				INFINITE MAGNIFICATION	DFOCSSI x NI/sqrt(Vr)
					ODFOCSCSI x NI/sqrt(Vr)
					ODFOCSICSI x NI/sqrt(Vr)
					CONTRASTSI x NI/sqrt(Vr)
					ORLCSI x OACSI
					ORPCSI x OACSI
					ORLCSI x ODFOCSCSI
					ORPCSI x ODFOCSCSI
					OACSI x ODFOCSCSI
					ORLICSITEM x OAICSI
					ORPICS/TEM x OAICSI
					ORLICSISTEM x OAICSI
					ORPICSISTEM x OAICSI
					ORLICSITEM x ODFOCSICSI
					ORPICSITEM x ODFOCSICSI
					ORLICSISTEM x ODFOCSICSI
					ORPICSISTEM x ODFOCSICSI
					OAICSI x ODFOCSICSI
					CONTRASTSI x DFOCSSI
					CONTRASTSI x RPSI
					RPSI x DFOCSSI

Figure 2-The commands can be excuting as computations and plots at developing of CADTEL software.

u	CONTRAST Schlmag.	CNTRSTS	11.0956306 42.7153657	146.898686	205.513561	259.5218346	304.1539273	336.7751551	356.7193773	364.8161903	362.5972682	352.6523936	336.6315738	316.381592	292.0381023	261.5247377	245.509207	210.8122519	198.1472898	182.3698745	
conditio	OPT.DEFOCUS. Incoh.sch.imag.	PSIICS(m)	0.6256339 0.0203141 0.0203040	0.0007384	0.0002702	0.0001239	0.0000666	0.0000403	0.0000267	0.0000191	0.0000144	0.0000114	0.0000094	0.00008	0.0000071	0.0000065	0.000058	0.0000057	0.0000051	0.0000048	
fication	OPT.DEFOCUS Consch.imag.	PSICS(m)	0.719479 0.0233612 0.0233612	0.0008491	0.0003108	0.0001424	0.0000766	0.0000463	0.0000307	0.0000219	0.0000166	0.0000131	0.0000108	0.000002	0.000081	0.0000075	990000000	0.0000065	0.0000059	0.0000055	
magni	DEFOCUS Schimag. (PSIS(m)	1.1699354 0.0379874 0.0279874	0.0013808	0.0005054	0.0002316	0.0001245	0.0000753	0.00005	0.0000356	0.000027	0.0000214	0.0000176	0.000015	0.0000132	0.0000122	0.0000108	0.0000106	0.0000096	0.0000089	
ns for zero	OPT.APRT. Incoh.sch.imag.	ALFAICS(rad)	0 0	91000000000000000	0.00000000067	0.0000000021	0.00000000533	0.00000000115	0.000000002194	0.000000003798	0.000000006077	0.000000009127	0.000000012994	0.000000017685	0.000000023044	0.00000028499	0.00000036219	0.000000041408	0.000000050995	0.000000060659	
ignetic le	OPT.APRT. Coh.Sch.imag.	ALFACS(rad)	0	0.0000000000000000000000000000000000000	0.00000000072	0.000000000225	0.000000000569	0.000000001228	0.000000002343	0.000000004056	0.00000000649	0.000000009747	0.000000013877	0.000000018885	0.000000024609	0.000000030433	0.00000038678	0.0000004422	0.000000054457	0.000000064777	PTURNS
osed ma	RESOLPOW.MIN. Schimag.	GAMASmin(I/nm)	0.0003004 0.0023133	0.159105	0.0278223	0.0421556	0.0576267	0.0728976	0.0868272	0.0986127	0.1077555	0.1142684	0.118115	0.1195094	0.1181735	0.1128925	0.1125796	0.1024042	0.1015862	0.0984224	= 605.12 AM
of prop	RESOLPOW. Schimag.	GAMAS(1/nm)	0.0012213 0.0094033	0.0646751	0.113096	0.1713599	0.234249	0.2963239	0.3529469	0.400854	0.4380191	0.4644934	0.4801297	0.485798	0.4803675	0.4589006	0.4576287	0.4162665	0.4129413	0.4000808	XCITATION OF N
r imaging	OPT.RESOL.POW. INCOHSCHSTEM	GAMAICSSTEM(1/nm)	0.0018148 0.0139733	8901960.0	0.16806	0.2546398	0.3480927	0.4403358	0.5244771	0.5956669	0.650894	0.6902347	0.7134701	0.7218932	0.7138235	0.6819237	0.6800337	0.6185698	0.6136284	0.5945179	RESULTS ARE FOR AN E
r Scherze	OPT.RESOL.POW. Incoh.sch.tem	GAMAICSTEM(I/nm)	0.0012793 0.00985 5100150	0.0677474	0.1184685	0.1795002	0.2453768	0.3104006	0.3697134	0.4198963	0.458827	0.4865589	0.502938	0.5088755	0.503187	0.4807003	0.479368	0.436041	0.4325577	0.4190864	THE ABOVE
tions fo	OPT.RESOLPOW. Coh.Sch.imag.	GAMACS(1/nm)	0.009083 0.0090083	0.0619579	0.1083445	0.1641606	0.2244076	0.2838746	0.3381187	0.3840131	0.4196169	0.4449789	0.4599583	0.4653884	0.460186	0.439621	0.4384025	0.3987781	0.3955925	0.3832724	
un condi	OPT.RESOLLIM. Incoh.sch.stem	SGMAICSSTEM(nm)	551.02 71.57	10.41	5.95	3.93	2.87		161	89.1	1.54	1.45	1.4	139	1.4	147	147	1.62	1.63	1.68	
e optimu	OPT.RESOLLIM. Incoh.sch.tem	SGMAICSTEM(nm)	781.67 101.52 10 CC	14.76	8.44	5.57	4.08	311	71	238	2.18	2.06	1.99	1.97	661	2.08	2.09	2.29	131	139	
le 2: Th	OPT.RESOLLIM. Coh.Sch.imag.	SGMACS(nm)	854.72 111.01 25.04	16.14	923	60.9	4.46	121	2.96	2.6	238	225	2.17	2.15	117	111	2.28	251	153	2.61	
Tab	SPHERICAL ABERRATION	G(m)	618.22651 10.03681	0.18241	0.05341	0.0204	0.0094	0.00498	0.00293	0.00188	0.0013	0.00094	0.00072	0.00057	0.00047	0.0004	0.00034	0.00031	0.00027	0.00024	
	WAVE Length	LMDA(nm)	0.00202 0.00405	0.0081	0.01012	0.01214	0.01417	0.01619	0.01822	0.02024	0.02226	0.02429	0.02631	0.02834	0.03036	0.03238	0.03441	0.03643	0.03846	0.04048	
	EXCITATION Parameter	NI/sqrt(Vr)	- ~ ~	- 4	5	9	-	~	6	2	=	17	m	14	15	91	11	8	61	20	
	BEAM Voltage	Vr(Kv)	366.1727 91.54318 40.60504	22.88579	14.64691	10.17146	7.47291	5.72145	4.52065	3.66173	3.02622	2.54287	2.1667	1.86823	1.62743	1.43036	1.26703	1.13016	1.01433	0.91543	

According to the above equations, the programing code for all proposed math models of lenses was written, to compute and plot the optimum conditions for Scherzer imaging.

At ZMC for a magnetic lens using GBSM and as a function of excitation parameter (NI/ \sqrt{Vr}), Figures 3-16 illustrate the optimum resolution limit (δ) for coherent Scherzer imaging, the optimum resolution limit (δ) for incoherent Scherzer imaging in TEM, the optimum resolution limit (δ) for incoherent Scherzer imaging in STEM, the optimum resolution power (γ) for coherent Scherzer imaging, the optimum resolution power (γ) for incoherent Scherzer imaging, the optimum resolution power (γ) for incoherent Scherzer imaging in STEM, the resolution power (γ) for incoherent Scherzer imaging, the resolution power (γ) for Scherzer imaging, the minimum resolution power (γ_{min}) for Scherzer imaging, the optimum aperture (α) for incoherent Scherzer imaging, the optimum aperture (α) for incoherent Scherzer imaging, the optimum defocus (ψ) for scherzer imaging, the optimum defocus (ψ) for coherent Scherzer imaging, and the contrast (χ) for Scherzer imaging.

The user can evaluate and observe the relations of the optimum resolution limit (δ) and the optimum resolution power (γ) as a function of optimum aperture (α) as shown in Figures 17 and 18, and as a function of optimum defocus (ψ) as illustrated in Figures 19and 20 respectively, for coherent Scherzer imaging at ZMC for magnetic lens using GBSM.

The development of CADTEL software provides the user the capability to study the effect of other parameters such as, the optimum aperture (α) as a function of optimum defocus (ψ) for coherent Scherzer imaging (Figure 21). In addition, as a function of optimum aperture (α), when the user can examine the optimum resolution limit (δ) in TEM, the optimum resolution power (γ) in TEM, the optimum resolution limit (δ) in STEM, and the optimum resolution power (γ) in STEM, as illustrated in Figures 22, 23, 24, and 25, respectively for incoherent Scherzer imaging at ZMC for magnetic lens using GBSM.

Thus, user can study the variation of numerous parameters such as the optimum resolution limit (δ) in TEM, the optimum resolution power (γ) in TEM, the optimum resolution limit (δ) in STEM, the optimum resolution power (γ) in STEM, the optimum aperture (α), and the contrast (χ) as a function of optimum defocus (ψ) as shown in Figures 26, 27, 28, 29, 30, and 31, respectively, for incoherent Scherzer imaging at ZMC using GBSM.

Finally, Figures 32 and 33 represent the relation between the contrast (χ) as a function of resolution power (γ), and the behavior of the resolution power (γ) as a function of defocus (ψ), respectively for Scherzer imaging at ZMC using GBSM.

6. Conclusions

In magnetic lenses, according to proposed mathematical model, which is selected from multichoices in the developed version of CADTEL software, using GBSM at ZMC, studying the optimum desirable design and observing the optimum conditions of coherent and incoherent Scherzer imaging, one can conclude:

✤ Optimum resolution limit for coherent and incoherent of TEM and STEM decreases exponentially with increasing the excitation parameters and the optimum aperture values.

* Increasing the resolving power and its optimum values is associated with the increase of the excitation parameters up to $NI/\sqrt{Vr} = 14$ and decreasing above this value..

✤ Exponential increment of the optimum aperture for coherent and incoherent Scherzer imaging occurs with increasing the excitation parameters.

✤ Defocus and its optimum values for coherent and incoherent Scherzer imaging exponentially decreases with decreasing the excitation parameters.

• Contrast rises with incrementing the excitation parameter up to NI/ \sqrt{Vr} =10, then going down after this value.

★ The optimum resolution power increases with increasing the optimum aperture and declining with the optimum defocus reaching to $\gamma = 0.465 \text{ nm}^{-1}$ for coherent Scherzer imaging, $\gamma = 0.508 \text{ nm}^{-1}$ in TEM for incoherent Scherzer imaging, and $\gamma = 0.721 \text{ nm}^{-1}$ in STEM for incoherent Scherzer imaging, then drops with the increase of optimum aperture and optimum defocus values.

✤ There is a general behavior of increase of the optimum resolution limit with raising the optimum defocus for coherent and incoherent Scherzer imaging of TEM and STEM.

 \bullet Thus, the optimum aperture decreases with the decrease of the optimum defocus in coherent and incoherent Scherzer imaging.

Also, the contrast increases with the decrease of the defocus up to $\chi = 364$ at $\psi = 0.000035$ m, after these values the contrast decreases with the decrease of defocus Scherzer imaging.

* Therefore, the contrast increases with incrementing the resolution power up to $\chi = 364$ at $\gamma = 0.4$ nm⁻¹, then dropping with the decrease of these values of resolution power.

The CADTEL software package is an important new tool for the design and analysis of electro-magnetic lenses. This software provides an interactive and intuitive programming package for the creation of symmetric and asymmetric lenses for one or more pole piece in both the analysis and synthesis process under four operating conditions. CADTEL provides a substantial decrease in time, and effort needed to inform a beginner user interested in this field. Therefore, the increased performance should be realized because from the field of electron optics.



Figure 3- The optimum resolution limit (δ) for coherent Scherzer imaging as a function NI/ \sqrt{Vr} at ZMC for magnetic lens using GBSM.



Figure 4-The optimum resolution limit (δ) for coherent Scherzer imaging in TEM as a function of NI/ \sqrt{Vr} at ZMC for magnetic lens using GBSM.

















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